

MAR 08 1983

Detroit Institute of Arts
Research Laboratory
ATTN: Abraham Joel
5200 Woodward Avenue
Detroit, MI 48202

License No. 21-20230-01

30-18124

Gentlemen:

Thank you for your letter dated January 26, 1983, informing us of the steps you have taken to correct the noncompliance identified in our letter dated December 14, 1982. With respect to Item 1, while your letter states that you have filed an application for an appropriate amendment to achieve corrective action for the item of noncompliance, it should be understood that no activity is in accord with NRC regulatory requirements unless and until it is specifically authorized in an NRC license. Steps should be taken to ensure that NRC licensed materials are hereafter possessed and used only as authorized by your license.

As a result of our telephone conversation on March 4, 1983, regarding Item 3, it is our understanding that you surveyed the laboratory and records of laboratory surveys will be maintained and available for our review. We will examine these matters during a future inspection.

Your cooperation with us is appreciated.

Sincerely,

D. J. Sreniawski

D. J. Sreniawski, Chief
Materials Radiation Protection
Section 2

cc w/ltr dtd 1/26/83:
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| SURNAME | Douglas/cw | Matson | Sreniawski | | | |
| DATE | 3/7/83 | | 3/7/83 | | | |